Docket No.: 067161-0135



IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of : Customer Number: 20277

Seiichi ENDO, et al. : Confirmation Number: 4114

Application No.: 10/757,438 : Group Art Unit: 2818

Filed: January 15, 2004 : Examiner: Ngan V. Ngo

For: NONVOLATILE SEMICONDUCTOR MEMORY DEVICE

INFORMATION DISCLOSURE STATEMENT

Mail Stop Amendment Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

Dear Sir:

This Information Disclosure Statement is being filed more than three months after the U.S. filing date and after the mailing date of a Final Rejection or Notice of Allowance, but before payment of the Issue Fee.

REQUEST TO CONSIDER REFERENCES AFTER CLOSE OF PROSECUTION AND BEFORE PAYMENT OF ISSUE FEE

The undersigned hereby requests consideration and entry of this Information Disclosure Statement and accompanying references under 37 CFR 1.97(d).

Please charge the processing fee under 1.17(p) of \$180.00 to Deposit Account 500417.

01/31/2006 HALI11 00000021 500417 10757438

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CERTIFICATION PARAGRAPH

The undersigned certifies that each item of information contained in this Information

Disclosure Statement was first cited in a communication from a foreign patent office in a

counterpart foreign application not more than three months prior to the filing of this Information

Disclosure Statement as described in 37 CFR 1.97(e)(1).

Each non-English language reference was cited in a corresponding foreign application office action and its relevance discussed therein. A copy of the foreign office action, together with an English language version thereof, is attached for the Examiner's information.

Please charge any shortage in fees due in connection with the filing of this paper, including extension of time fees, to Deposit Account 500417 and please credit any excess fees to such deposit account.

Respectfully submitted,

McDERMOTT WILL & EMERY LLP

Gene Z. Rubinson Registration No. 33,351

Please recognize our Customer No. 20277 as our correspondence address.

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Facsimile: 202.756.8087 **Date: January 27, 2006**



SHEET 1 OF 1

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					APPLICANT Seiichi ENDO, et al.					
(PTO-1449)					FILING DATE January 15, 200	FILING DATE GROUP 2818				
U.S. PATENT DOCUMENTS										
EXAMINER'S INITIALS	CITE NO.		Document Number ber-Kind Code2 (# known)	Publication Dat MM-DD-YYYY		Pages, Columns, Lines, Where Relevant Passages or Relevant Figures Appear			ssages or	
		US	5,841,165	11/24/1998	Chang et al.	Previously submitted on June 9, 2005 Corresponds to JP 10-070203				
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FOREIGN PATENT DOCUMENTS										
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		JP 10-070203		03/10/1998	PROGRAMMABLE MICROELECTRON CORP.		responds to 5 5,841,165	JAPAN (w/English Abstract)		
	 									
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OTHER ART (Including Author, Title, Date, Pertinent Pages, Etc.)										
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^{*}EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.

1 Applicant's unique citation designation number (optional). 2 Applicant is to place a check mark here if English language Translation is attached.